

SRAM DIE

1 MEG SRAM

128K x 8, 64K x 16

FEATURES

- Single +3.3V or +5V power supply
- 5V tolerant I/O
- Individual byte controls for both READ and WRITE
- High-performance, low-power, CMOS double-metal
- All inputs and outputs are TTL-compatible

GENERAL PHYSICAL SPECIFICATIONS

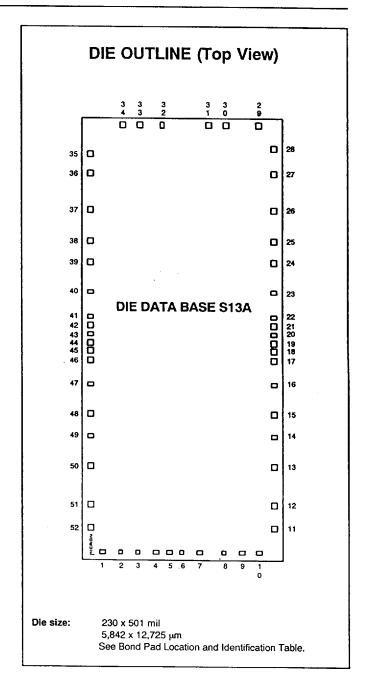
- Wafer thickness = 18.5 mils ±0.5 mils
- Backside wafer surface of polished bare silicon
- Typical metalization thickness 10K angstroms for the top level of metalization
- Typical lower-level metal thickness is 5.5K angstroms
- Metalization composition: 99.5% Al and 0.5% Cu over
- Typical topside passivation 6K angstroms phosphorous doped oxide with 6K angstroms of nitride over
- Typical passivation openings: $5.1 \times 5.1 \text{ mil}$ $130 \times 130 \mu m$

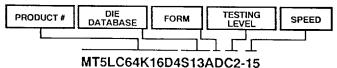
OPTIONS	ORDER NUMBER				
 Speed probing* 	3.3V	5V			
No speed probing	none	none			
12ns access	n/a	-12*			
15ns access	-15 ⁻	-15+			
20ns access	-20**	-20			
25ns access	-25	n/a			
• Form					
Die	I)			
Wafer (6" wafer)	V	V			
 Testing levels** 					
Standard probe	C	1			
Speed probe	C	2			
*Refer to "Speed Probing" section of this data sheet. Speed designator					

should not be included in die part number for CI level product.

ORDER INFORMATION

•	64K x 16	(+5V)	MT5C64K16A1S13A
•	64K x 16	(+3.3V)	MT5LC64K16D4S13A
•	128K x 8	(+5V)	MT5C128K8A1S13A
٠	128K x 8	(+3.3V)	MT5LC128K8D4S13A





^{**}Refer to "Die Testing Procedures" section of this data sheet.

^{*}Available as C2 level product only.



DIE TESTING PROCEDURES

Micron has established three testing levels for die products. Most Micron products are tested to Standard Probe (C1) level. Selected products are available at Speed Probe (C2) level. Known Good Die (C3) level product is available on selected products as market demand dictates. Level C2 and C3 products are designed to provide customers with improved yields over C1.

STANDARD PROBE (C1)

Micron probes wafers at a temperature with limits guardbanded to assure product performance from 0°C to 70°C on Micron's standard package. Since the package environment is not within Micron's control, the user must determine the necessary heat sinking requirements to ensure that the junction die temperature remains within specified limits. A high voltage functional stress test will be performed at probe to assure minimum junction breakdown integrity. VBB (substrate bias voltage) is a forced condition at wafer probe.

Wafer probe consists of various functional and parametric tests of each die. Test patterns, timing, voltage margins, limits and test sequence are determined by individual product yields and reliability data.

Micron retains a wafer map of each wafer as part of the probe records along with a lot summary of wafer yields for each lot probed. Micron reserves the right to change the probe program at any time to improve the reliability, packaged device yield or performance of the product.

SPEED PROBE (C2)

In addition to the testing performed at Standard Probe (C1), Micron also offers Speed Probe (C2). Micron's Hot Chuck Speed Probe assures the speed performance of die products for the fastest speed grades. Although this testing level may increase the yield a customer may see over C1-

level, the C2-level die has not received burn-in and therefore is still subject to infant mortality failures.

KNOWN GOOD DIE (C3)

In order to provide the customer with fully warranted die product, Micron has developed a Known Good Die process designed to provide customers with die products of equal quality and reliability to packaged product. Micron's KGD^{Plus} process allows Micron to fully test and burn-in die product.

FUNCTIONAL SPECIFICATIONS

Please refer to the packaged product data sheets found in the applicable Micron data book, for functional and parametric specifications. The specifications are provided for reference only on C1- and C2-level die product. On C2-level product ^tAA is guaranteed. C3-level product is warranted to the data sheet.

BONDING INSTRUCTIONS

The S13A SRAM die has 52 bond pads. Refer to the bond pad location and identification table for a complete list of bond pads and coordinates.

The S13A SRAM die has an internal substrate bias generator for normal operation, bond pad 6 is used for manufacturing tests only. Normal bonding leaves bond pad 6 open (not bonded). Micron recommends using a bond wire on each Vcc and Vss bond pad for improved noise immunity. It is important that the back of the die be kept isolated from any other devices sharing a common package or substrate, since the die substrate is internally driven to a negative voltage.

The 1 Meg SRAM device operates from a single +5V or 3.3V power supply and all inputs and outputs are fully TTL- compatible.



PACKAGING

For packaging, Micron utilizes Gel-Pak*. We package all die with the top metalization consistently oriented (refer to Figure 1). External packaging is suitable for electrostatic discharge protection. Each package is individually self-locking, or closed with a conductive clip and labeled with the following information:

- Generic device type and data base (Ex: 64K16S13A)
- · Micron fabrication lot number
- · Speed grade of the die (optional)
- · Quantity of die in package

STORAGE REQUIREMENTS

Micron die products are packaged for shipping in a cleanroom environment. Upon receipt, the customer should transfer the Gel-Pak to a similar environment for storage. Micron recommends the die be maintained in a filtered nitrogen atmosphere until removed for assembly. The moisture content of the storage facility should be maintained at 30 percent relative humidity. ESD damage precautions are necessary during handling. The die must be in an ESD-protected environment at all times for inspection and assembly.

PRODUCT RELIABILITY MONITORS

Reliability of all products is monitored by ongoing QA reliability evaluations. Micron's QA department samples product families on a continuous basis for reliability studies. These studies include high temperature operating life (HTOL) tests for failure in time (FIT) calculations and high temperature steady state (HTSS) tests to monitor electromigration reliability. A summary of these product family evaluations is published on a regular basis.

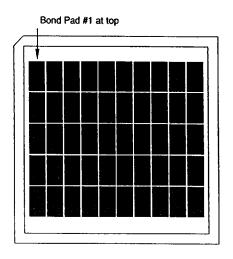


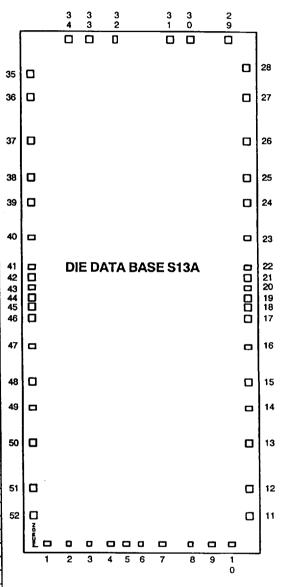
Figure 1
ORIENTATION OF DIE IN GEL-PAK



BOND PAD LOCATION AND IDENTIFICATION TABLE								
					NTER OF #1			
PAD #	MT5C64K16A1S13A	MT5C128K8A1S13A	"X"		"X"	"γ"		
		MT5LC128K8D4S13A	INCHES	INCHES	MICRONS	MICRONS		
1	ŌĒ	A7	0.000	0.000	000	000		
2	A7	DNU	0.000	-0.020	000	-508		
3	A6	A6	0.000	-0.040	000	-1,016		
4	A5	A5	0.000	-0.060	000	-1,524		
5	DNU*	A4	0.000	-0.075	000	-1,905		
6	DNU	DNU	0.000	-0.090	000	-2,286		
7	A4	DNU	0.000	-0.110	000	-2,794		
8	A3	A3	0.000	-0.138	000	-3,505		
9	A2	A2	0.000	-0.158	000	-4,013		
10	A1	A1	0.000	-0.178	000	-4,521		
11	A0	A0	0.027	-0.196	686	-4,978		
_12	CE	CE	0.054	-0.196	1,372	-4,978		
13	DQ1	DNU	0.097	-0.196	2,464	-4,978		
14	DQ2	DQ1	0.131	-0.196	3,327	-4,978		
15	DQ3	DNU	0.156	-0.196	3,962	-4,978		
16	DQ4	DQ2	0.190	-0.196	4,826	-4,978		
17	VCC	VCC	0.218	-0.196	5,537	-4,978		
18	VCC	VCC	0.228	-0.196	5,791	-4,978		
19	VCC	VCC	0.237	-0.196	6,020	-4,978		
20	VSS	VSS	0.247	-0.196	6,274	-4,978		
21	VSS	VSS	0.257	-0.196	6,528	-4,978		
22	VSS	VSS	0.267	-0.196	6,782	-4,978		
23	DQ5	DQ3	0.295	-0.196	7,493	-4,978		
24	DQ6_	DNU	0.329	-0.196	8,357	-4,978		
25	DQ7	DQ4	0.354	-0.196	8,992	-4,978		
26	DQ8	DNU	0.388	-0.196	9,855	-4,978		
27	WE	WE	0.430	-0.196	10,922	-4,978		
28	DNU	A16	0.458	-0.196	11,633	-4,978		
29	A15	A15	0.485	-0.179	12,319	-4,547		
30_	A14	A14	0.485	-0.142	12,319	-3,607		
31	A13	A13	0.485	-0.121	12,319	-3,073		
32_	A12	A12	0.485	-0.068	12,319	-1,727		
33	A11	A11	0.485	-0.043	12,319	-1,092		
34	A10	A10	0.485	-0.023	12,319	-584		
35	A9	A9	0.458	0.014	11,633	356_		
36	A8	A8	0.430	0.014	10,922	356		
37	DQ9	DNU	0.388	0.014	9,855	356		
38 39	DQ10	DQ5	0.354	0.014	8,992	356		
	DQ11	DNU	0.329	0.014	8,357	356		
40	DQ12	DQ6	0.295	0.014	7,493	356		
41 42	VCC	VCC	0.267	0.014	6,782 6,528	356		
	VCC					356		
43 44	VCC	VCC	0.247	0.014	6,274 6,020	356		
		VSS				356		
45 46	VSS VSS	VSS	0.228	0.014	5,791	356		
46	DQ13	DQ7	0.218	0.014	5,537 4,826	356		
47	DQ14	DNU	0.190	0.014		356		
48	DQ15	DQ8	0.130	0.014	3,962	356		
	DQ16	DNU			3,327	356		
50 51	BLE	OE OE	0.097	0.014	2,464 1,372	356 356		
		. (11"			1 1.577			

*"DNU" stands for do not use

DIE OUTLINE (Top View)



Wafer diameter:

150mm

Wafer thickness:

Bond pad size:

18.5 mil ±0.5 mil

Die size:

230 x 501 mil

(stepping interval)

5,842 x 12,725 µm

5.8 x 5.8 mil

146 x 146 μm

Passivation

Openings

(typical):

5.1 x 5.1 mil

130 x 130 μm